
EDITORS

Senior Editors:

S. Z. D. Cheng T. Hashimoto A. H. E. Müller

Honorary Editors:

Y. Imanishi I. M. Ward

Asian Editors:

Professor C. C. Han (all subject areas from China)
Joint Laboratory of Polymer Science and Materials,
Institute of Chemistry, The Chinese Academy of Sciences,
Zhongguancun, Beijing, 100080, China

Professor K. Tashiro

 (*physics*)

Department of Future Industry-oriented Basic Science and
Materials, Graduate School of Engineering, Toyota Technological
Institute, Hisakata 2-12-1, Tempaku, Nagoya 468-8511, Japan

Professor S. Ito

 (*physical chemistry and functionality*)

Department of Polymer Chemistry, Graduate School of Engineering,
Kyoto University, Katsura Campus, Kyoto 615-8510, Japan

Professor T. Masuda

 (*chemistry and synthesis*)

Department of Polymer Chemistry, Graduate School of Engineering,
Kyoto University, Katsura Campus, Kyoto 615-8510, Japan

Editors for the Americas:

Professor S. Z. D. Cheng (*physics and physical chemistry*)
Maurice Morton Institute and Department of Polymer Science,
Goodyear Polymer Centre, Room 936, University of Akron, Akron,
OH 44325-3909, USA

Professor S. R. Turner (*chemistry and synthesis*)
Macromolecules and Interfaces Institute, Virginia Tech,
Blacksburg, VA 24061, USA

European & Rest of the World (outside the Americas and Asia) Editors:

Professor G. Krausch (*physics*)
Physikalische Chemie II, Universität Bayreuth,
D-95440 Bayreuth,
Germany

Professor M. Ballauff

 (*physical chemistry*)

Physikalische Chemie I, Universität Bayreuth,
D-95440 Bayreuth,
Germany

Professor A. H. E. Müller

 (*chemistry and synthesis*)

Makromolekulare Chemie II, Universität Bayreuth,
D-95440 Bayreuth, Germany

Computational and Theoretical Polymer Science Editor:

Professor J. E. Mark
Department of Chemistry, University of Cincinnati,
Cincinnati, OH 45221-0172, USA

EDITORIAL ADVISORY BOARD

A. Abe
Tokyo Institute of Polytechnics, Japan
W. W. Adams
Rice University, TX, USA
M. Antonietti
Max Planck Institute of Colloids and Interfaces,
Potsdam, Germany
D. C. Bassett
University of Reading, UK
N. C. Billingham
University of Sussex, UK
D. C. Bott
National Starch & Chemical, High Wycombe
W. Burghardt
Northwestern University, Evanston, IL, USA
B. Charleux
Université Pierre et Marie Curie, Paris, France
S. Chen
National Tsing Hua University, Taiwan,
Republic of China
Y. Chen
The Chinese Academy of Sciences, Beijing, China
F. Ciardelli
University of Pisa, Italy
R. J. Composto
University of Pennsylvania, PA, USA
J. M. G. Cowie
Heriot-Watt University, Edinburgh, UK
C. De Rosa
Università di Napoli Federico II, Naples, Italy
F. Du Prez
Ghent University (RUG), Ghent, Belgium
B. Farmer
Wright-Patterson Airforce Base, OH, USA
W. J. Feast
University of Durham, UK
S. Förster
Universität Hamburg, Hamburg, Germany
C. W. Frank
Stanford University, CA, USA
J. Fried
University of Cincinnati, OH, USA
J. Gerzer
North Carolina State University, Raleigh, NC, USA
E. Giannelis
Cornell University, Ithaca, NY, USA
R. G. Gilbert
University of Sydney, NSW, Australia
S. Grannick
University of Illinois at Urbana-Champaign,
Urbana, IL, USA
Y. Gnanou
ENSIC-Université Bordeaux I, Talence, France
R. H. Grubbs
California Institute of Technology, Pasadena,
CA, USA
F. W. Harris
University of Akron, OH, USA

C. J. Hawker
University of California, Santa Barbara, CA, USA
J. N. Hay
University of Birmingham, UK
M. Hillmyer
University of Minnesota, Minneapolis, MN, USA
P. Hodge
University of Manchester, UK
B. S. Hsiao
State University of New York, NY, USA
M. B. Huglin
University of Salford, UK
R. A. L. Jones
University of Sheffield, UK
T. Kajiyama
Kyushu University, Japan
F. Khoury
National Institute of Standards and Technology,
Gaithersburg, MD, USA
J. K. Kim
Pohang University of Science and Technology,
Pohang, Korea
T. Kitayama
Department of Chemistry, Osaka University,
Japan
L. Leibler
ESPCI, Paris, France
A. Ledwith
Wigan, UK
P. J. Lemstra
Eindhoven University of Technology,
The Netherlands
T. P. Lodge
University of Minnesota, Minneapolis, MN, USA
B. A. Lotz
Institut Charles Sadron, Strasbourg, France
A. J. Lovinger
Bell Laboratories, Lucent Technologies,
Murray Hill, NJ, USA
C. Macosko
University of Minnesota, Minneapolis, MN, USA
R. H. Marchessault
McGill University, Montreal, Canada
K. Matyjaszewski
Carnegie Mellon University, Pittsburgh, PA, USA
J. E. McGrath
Virginia Polytechnic Institute and State University,
Blacksburg, VA, USA
E. W. Meijer
Eindhoven University of Technology,
The Netherlands
M. Muthukumar
University of Massachusetts, Amherst, MA, USA
H. Nishide
Waseda University, Japan
D. R. Paul
University of Texas, Austin, TX, USA

R. E. Prud'homme
Université de Montréal, Montréal, Canada
R. A. Register
Princeton University, Princeton, NJ, USA
S. B. Ross-Murphy
King's College, London, UK
G. C. Rutledge
Massachusetts Institute of Technology, Cambridge,
MA, USA
A. J. Ryan
University of Sheffield, UK
S. Sakurai
Kyoto Institute of Technology, Japan
I. Sanchez
University of Texas, Austin, TX, USA
K. Schmidt-Rohr
Iowa State University, IA, USA
M. Shibayama
University of Tokyo, Japan
R. A. Siegel
University of Minnesota, Minneapolis, USA
S. L. Smith
Texas Tech University, Lubbock, TX, USA
P. Smith
ETH Zürich, Switzerland
R. Stepto
University of Manchester, UK
G. Strobl
Albert-Ludwigs-Universität, Freiburg,
Germany
U. W. Suter
ETH Zürich, Switzerland
E. L. Thomas
Massachusetts Institute of Technology, Cambridge,
MA, USA
M. Tsuji
Kyoto University, Japan
V. Tsukruk
Georgia Institute of Technology, Atlanta, GA, USA
F. Wang
The Chinese Academy of Science, Beijing,
P. R. China
Z. Y. Wang
Carleton University, Ottawa, Canada
G. Wegner
Max-Planck-Institute for Polymer Research, Mainz,
Germany
J. G. Williams
Imperial College, London, UK
A. H. Windle
University of Cambridge, Cambridge, UK
C. Wu
The Chinese University of Hong Kong, Shatin,
Hong Kong
Y. Yagci
Istanbul Technical University, Istanbul, Turkey
Q.-F. Zhou
Peking University, Beijing, China